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(54) **LOCAL OSCILLATOR DISTRIBUTION FOR A MILLIMETER WAVE SEMICONDUCTOR DEVICE**

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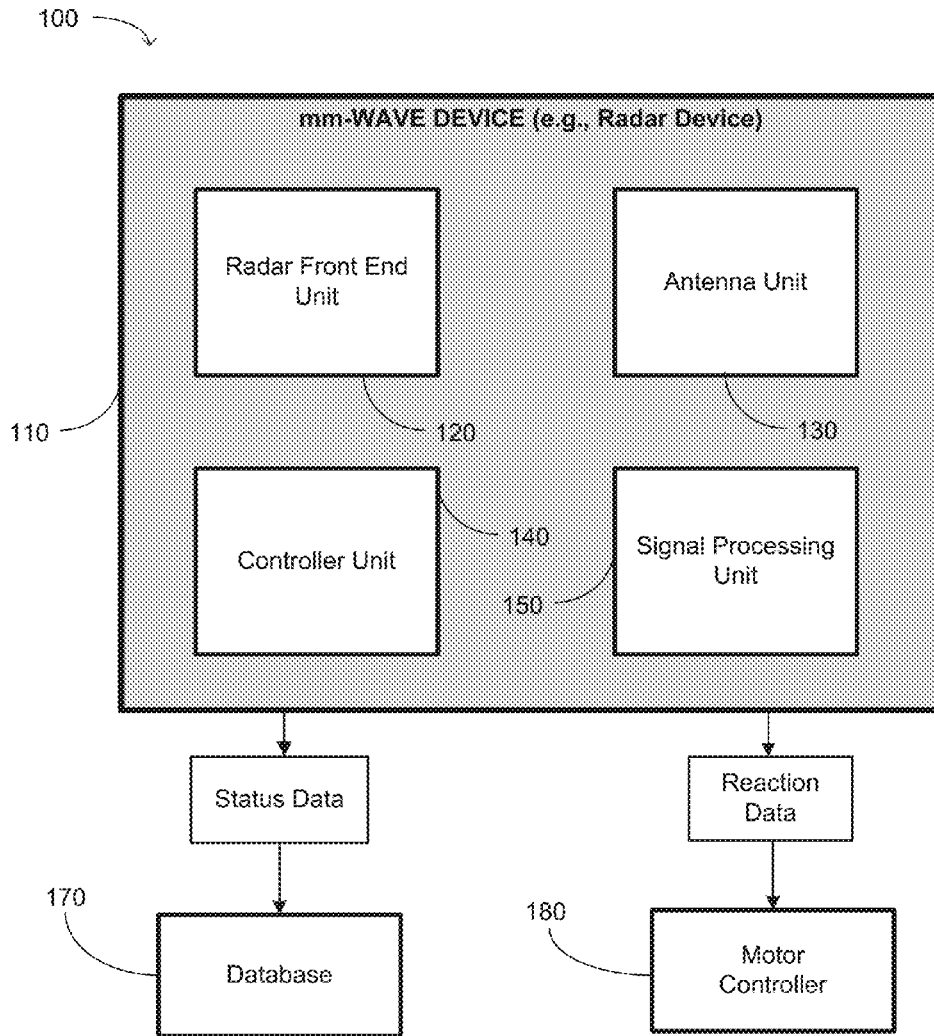
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H01P 5/16 (2006.01)

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 CPC *H03B 1/02* (2013.01); *H01P 5/16* (2013.01); *H03H 11/36* (2013.01); *H03B 5/1203* (2013.01)

(57) **ABSTRACT**

A CMOS gain element is disclosed herein. Also disclosed herein are splitters, comprising the CMOS gain element, and local oscillator distribution circuitry comprising the splitters and the CMOS gain elements. Semiconductor devices comprising the local oscillator distribution circuitry may have smaller footprints and reduced power consumption relative to prior art devices.



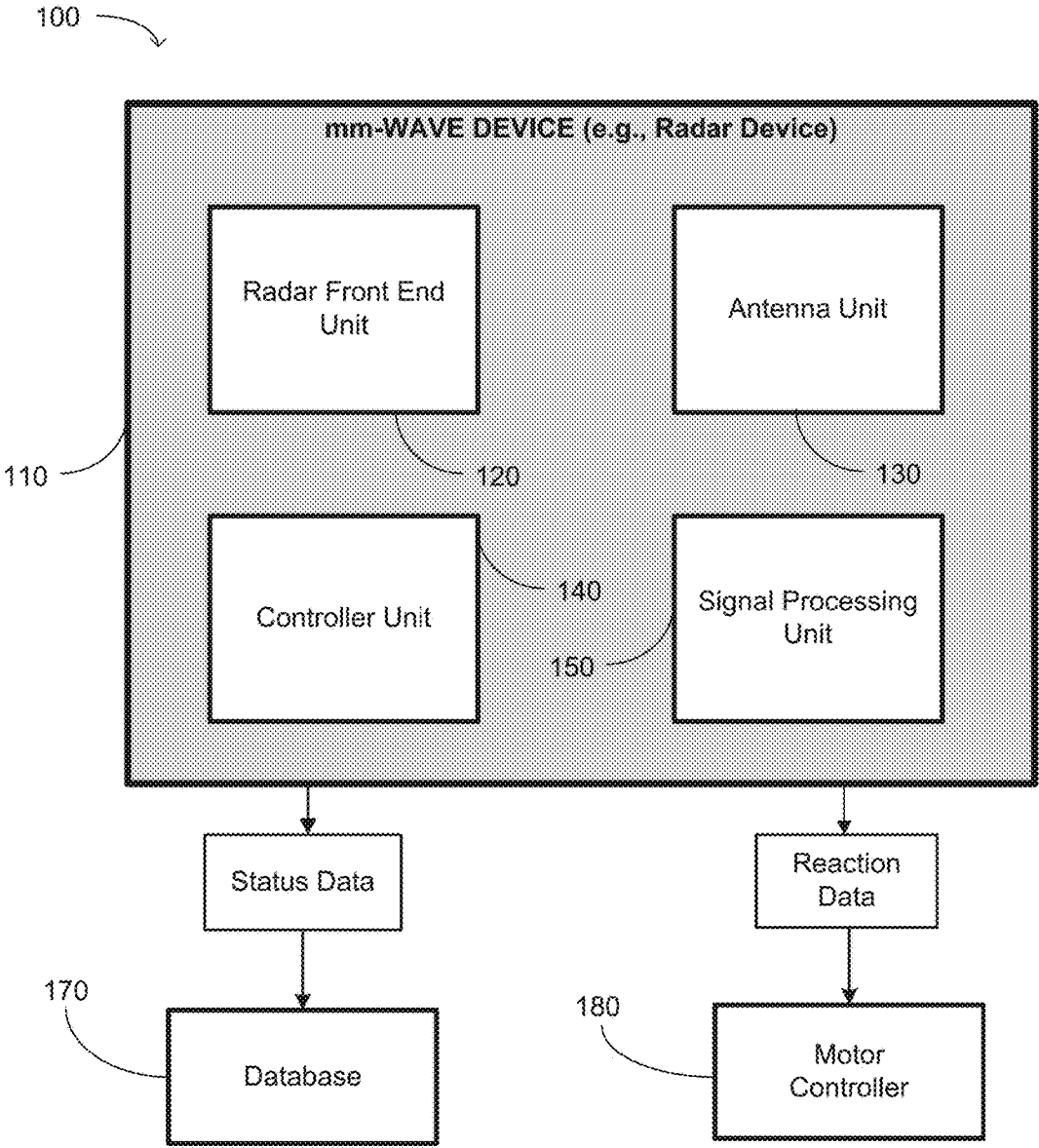


FIG. 1

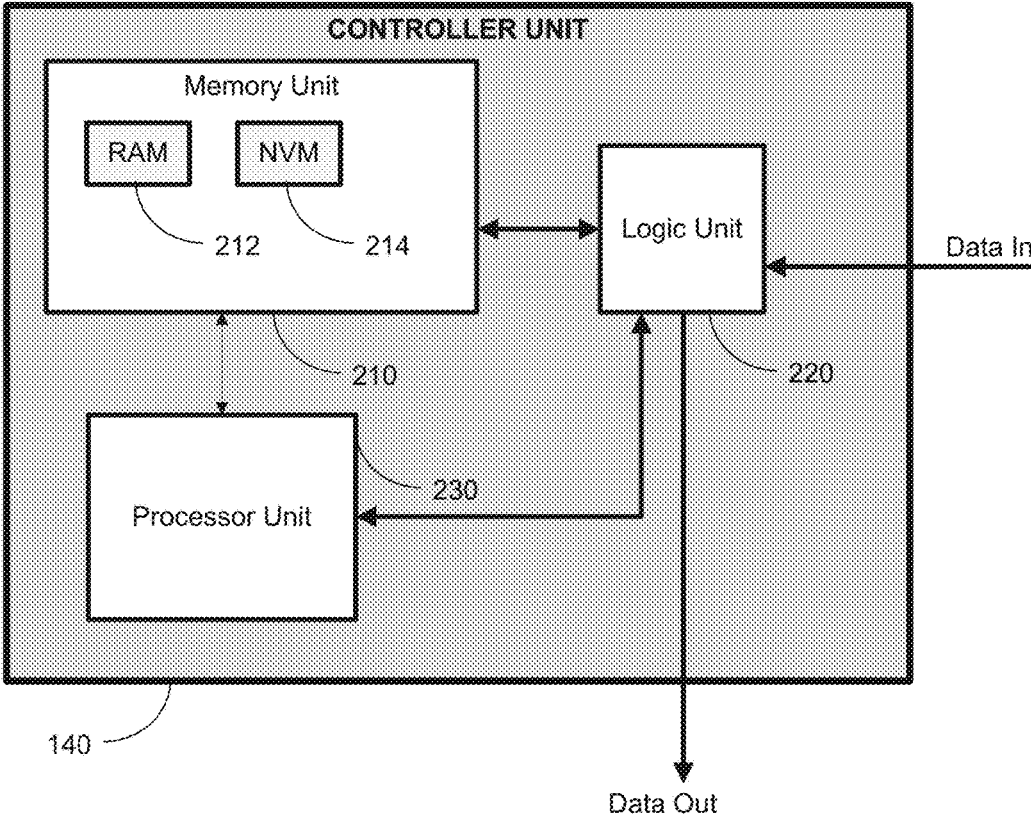


FIG. 2

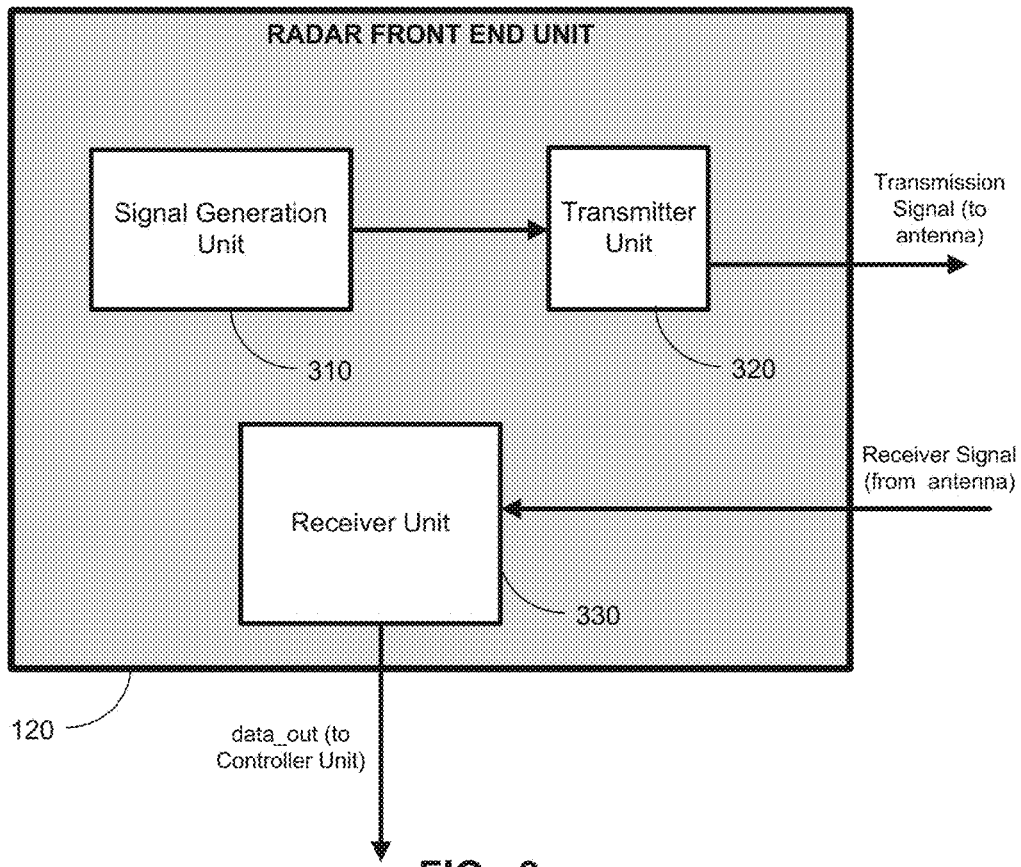


FIG. 3

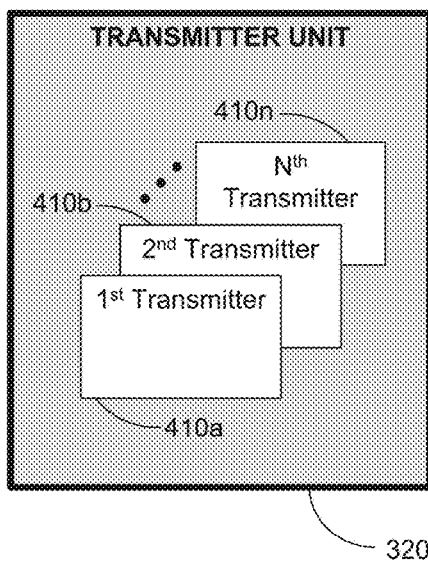


FIG. 4

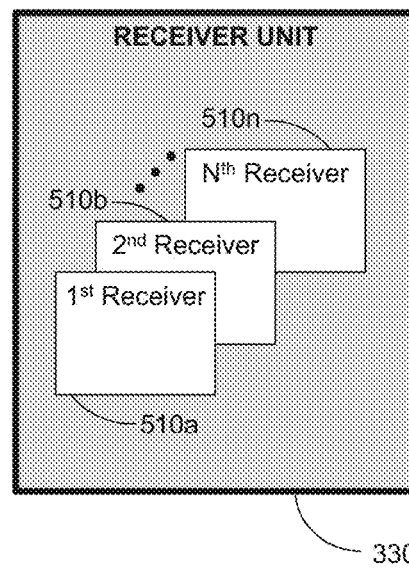


FIG. 5

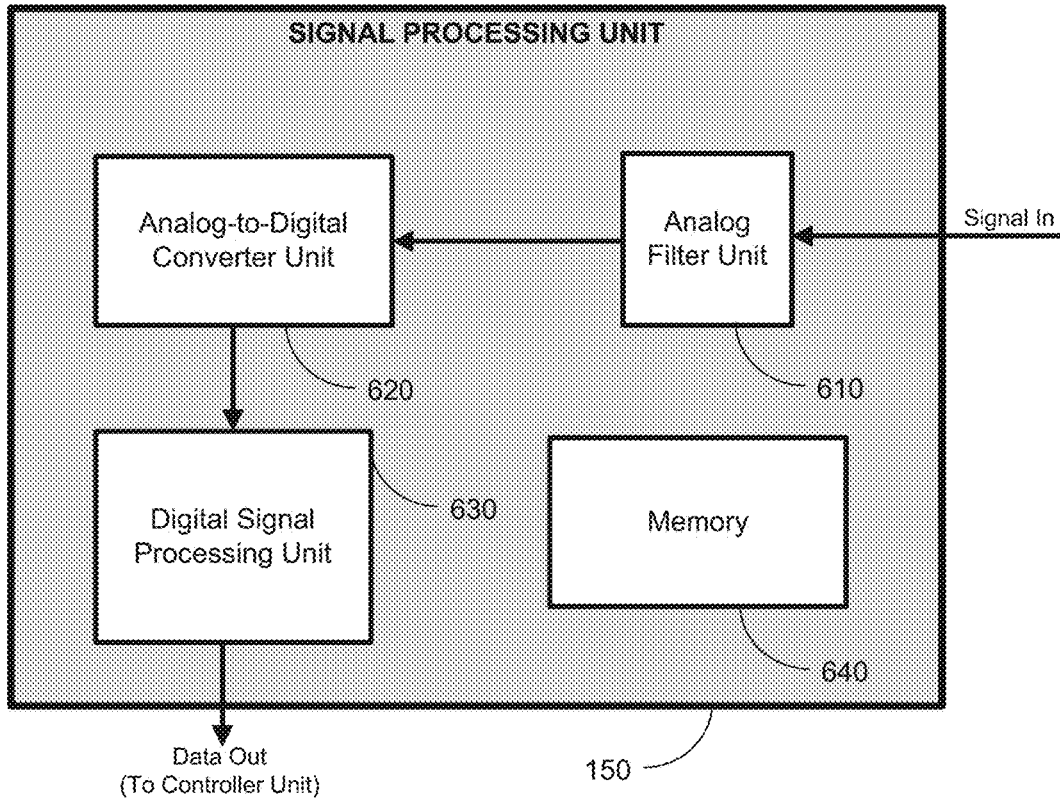


FIG. 6

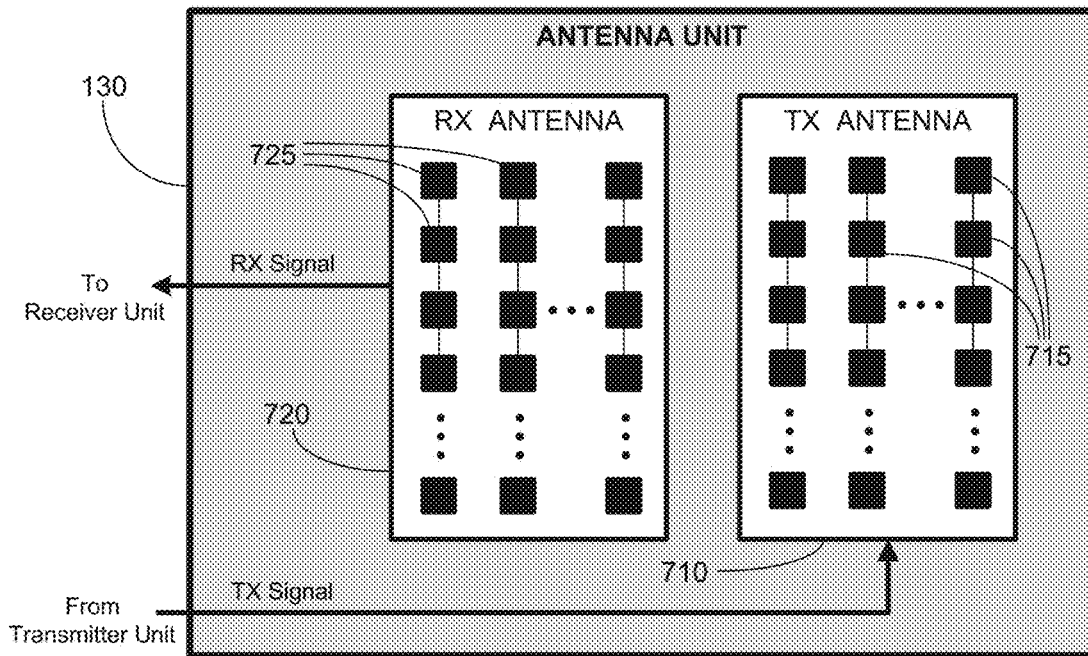


FIG. 7

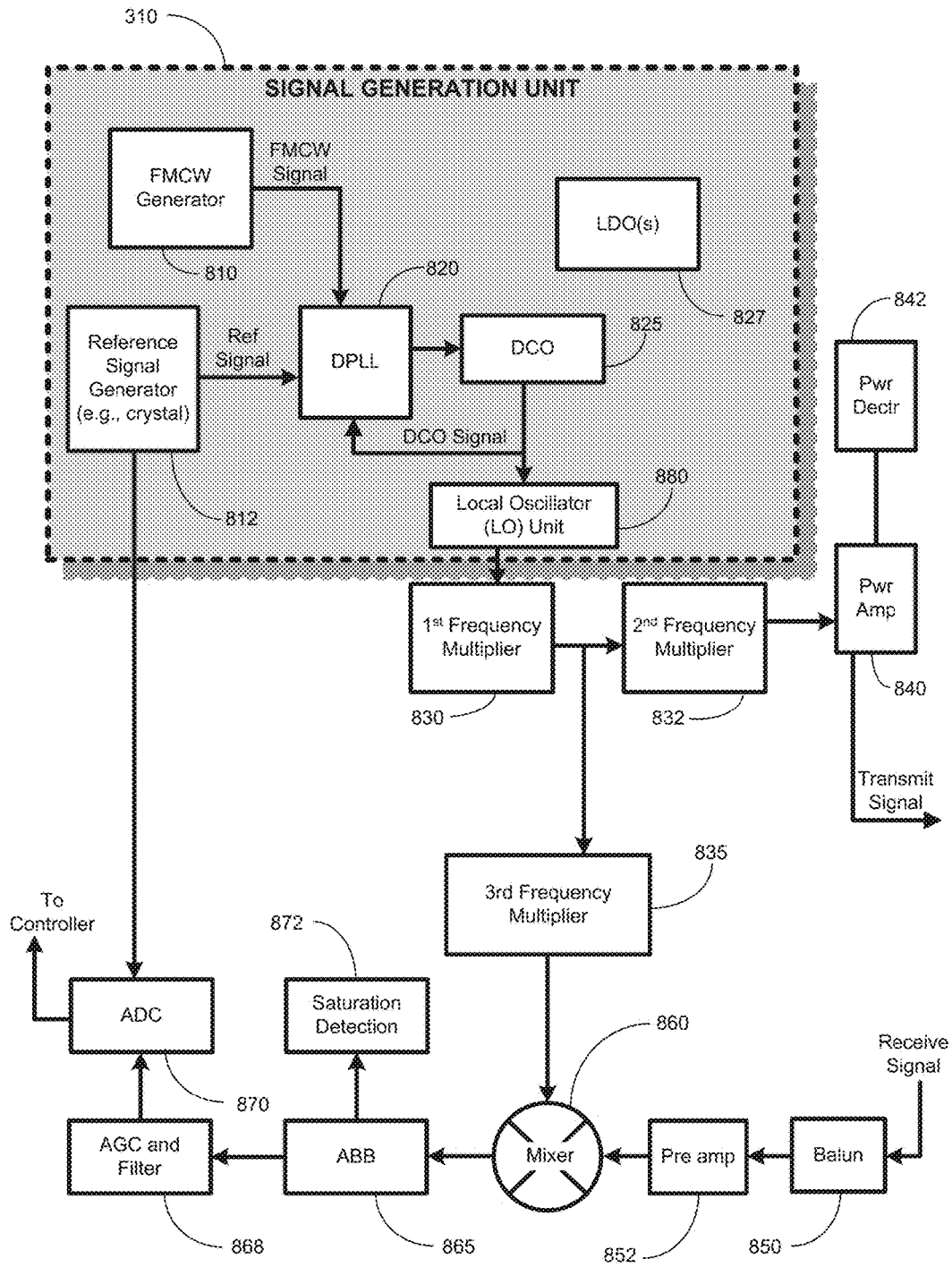


FIG. 8

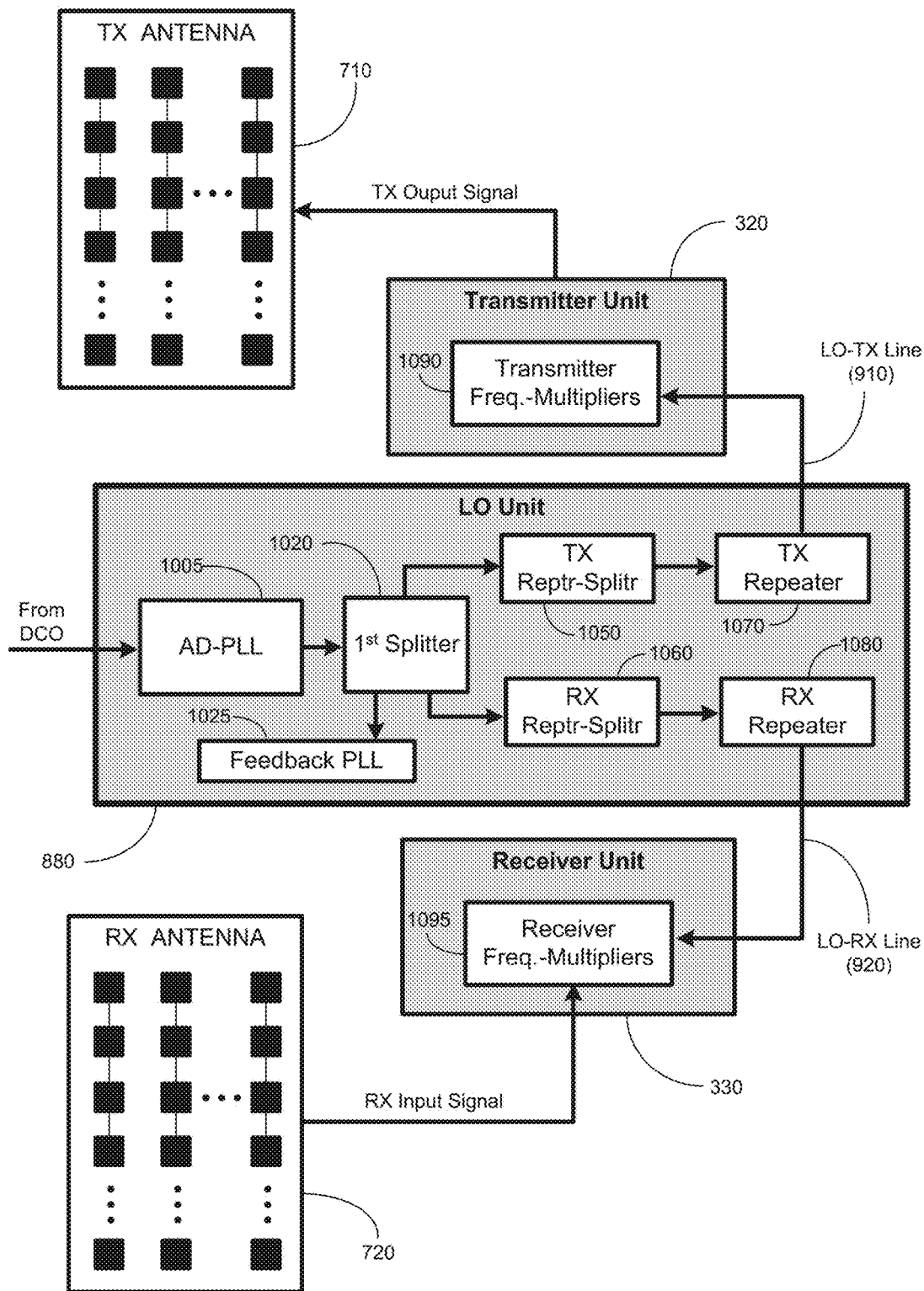


FIG. 9

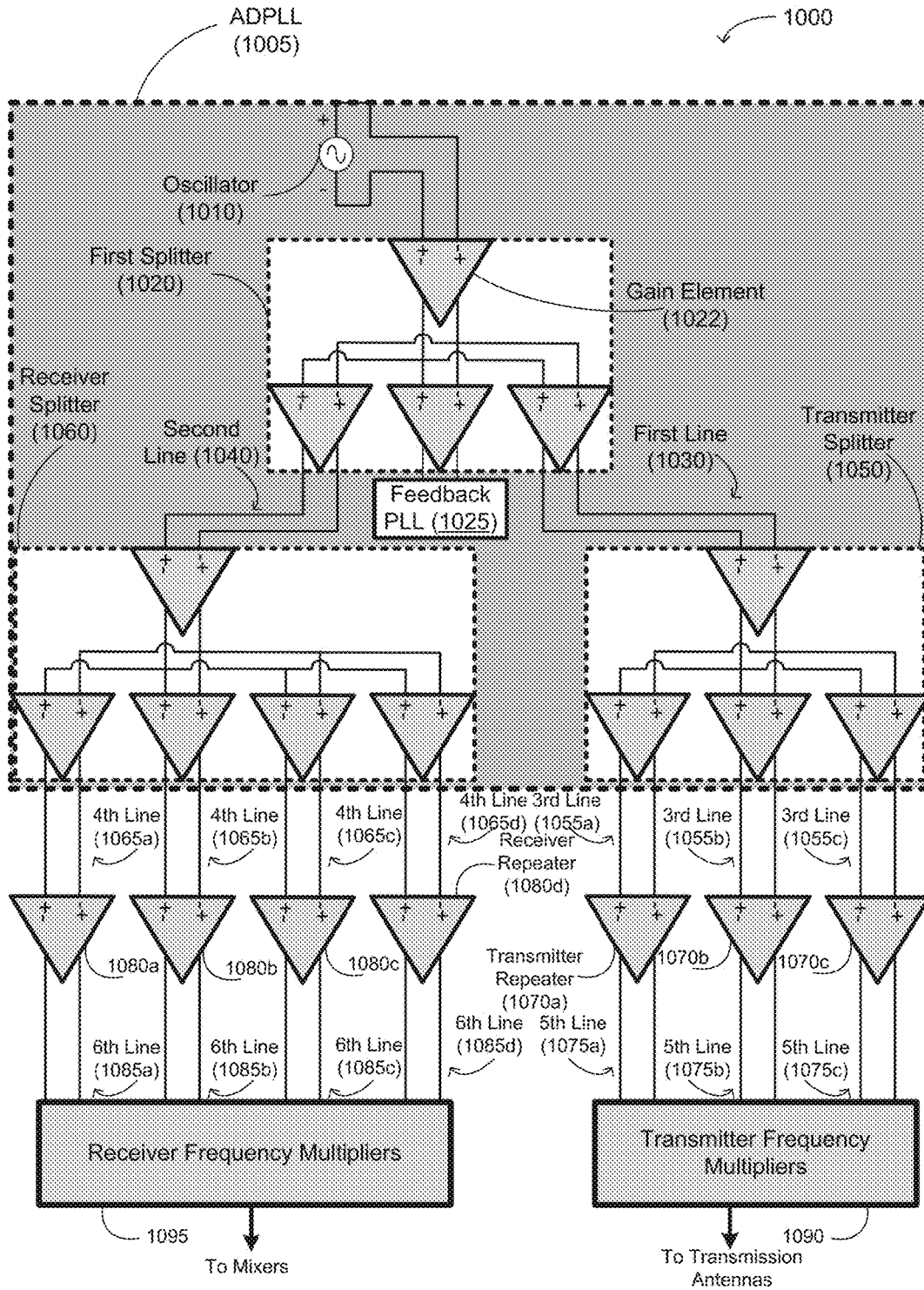
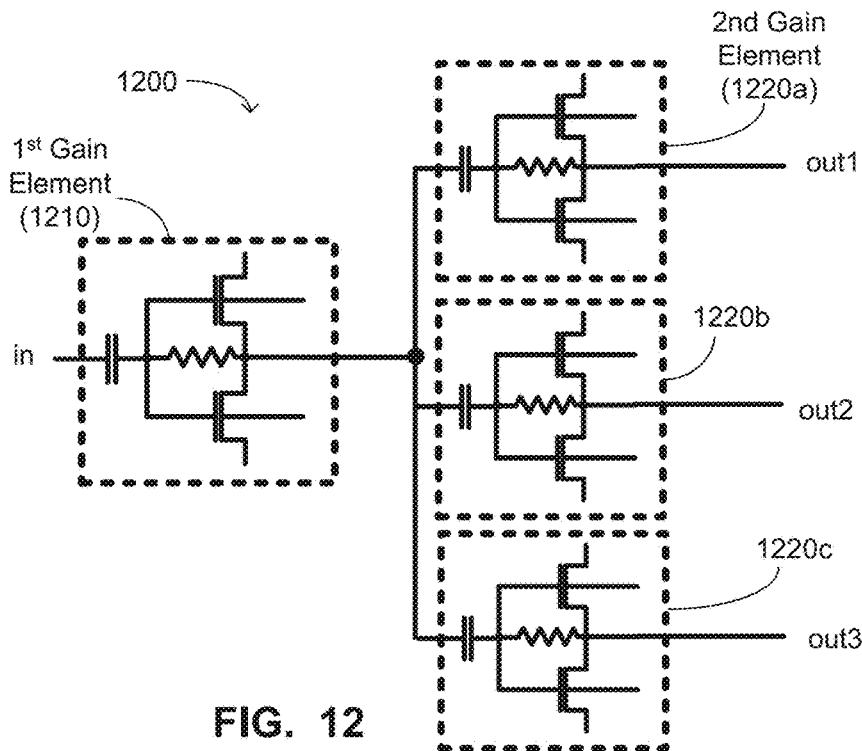
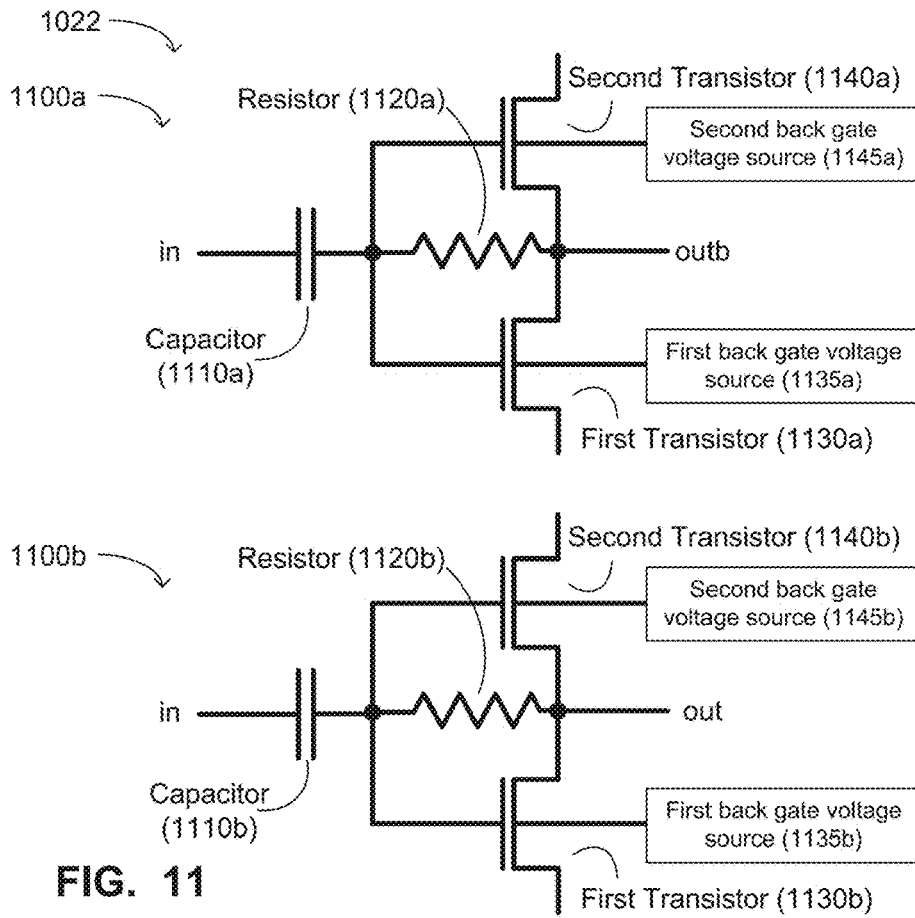


FIG. 10



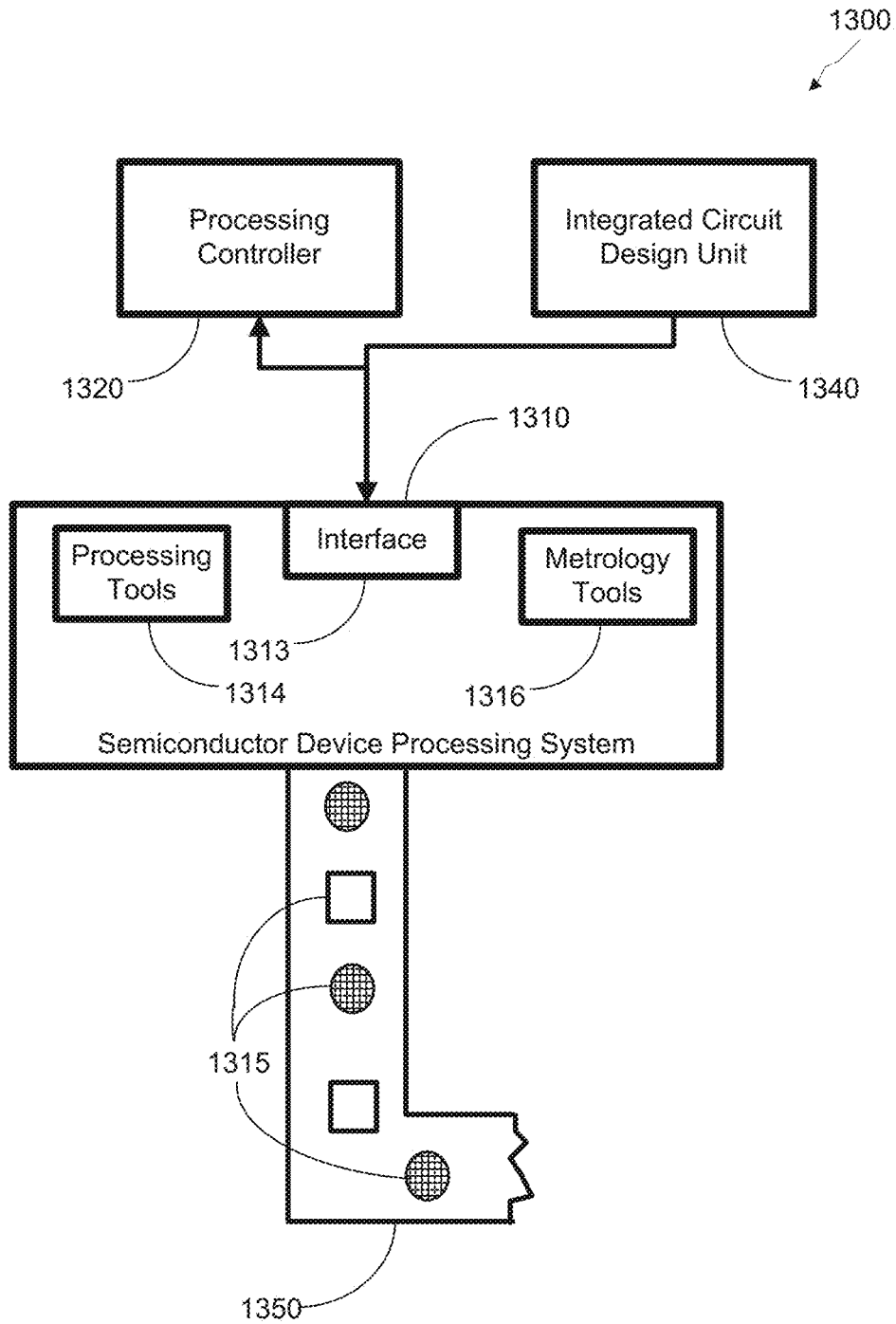


Fig. 13

LOCAL OSCILLATOR DISTRIBUTION FOR A MILLIMETER WAVE SEMICONDUCTOR DEVICE

BACKGROUND OF THE INVENTION

Field of the Invention

[0001] Generally, the present disclosure relates to sophisticated semiconductor devices and, more specifically, to distribution of a mm-wave local oscillator signal, CMOS gain element, and semiconductor devices comprising the same.

Description of the Related Art

[0002] In an effort to maintain Moore's Law as a self-fulfilling prophecy, the semiconductor industry in recent years has sought to reduce the sizes of semiconductor devices. Also, in an effort to reduce operating expenses of semiconductor device, the semiconductor industry in recent years has sought to reduce the energy consumption of semiconductor devices. This is particularly a concern in semiconductor devices that operate in the millimeter wave (mm-wave) range.

[0003] Semiconductor devices that involve mm-wave applications include devices that operate based on the electromagnetic spectrum of radio band frequencies in the range of about 30 GigaHertz (GHz) to about 300 GHz. The mm-wave radio waves have a wavelength in the range of 1 millimeter (mm) to about 10 mm, which corresponds to a radio frequency of 30 GHz to about 300 GHz. This band of frequencies is sometimes referred to as extremely high frequency (EHF) frequency band range. Examples of applications of mm-wave application include radar devices, high-speed communication devices (e.g., wireless gigabit (Wi-Gig) devices, etc. Radar devices have been implemented in various applications such as vehicle safety and automation applications.

[0004] Implementing mm-wave applications produces many challenges when designing circuits for these applications. A number of device types that involve mm-wave applications require the splitting or dividing of signals. For example, in semiconductor devices, such as automotive radars and wireless telephones meeting the 5G standard, which comprise a plurality of transmitter and/or receiver antennas, a timing signal provided by an oscillator may be split to provide a timing signal to each antenna.

[0005] Because splitting a signal reduces the output signal's power, splitting requires power dividers to maintain the power of each split signal equal to the power of the input signal. Also, given that power is lost with distance of signal transmission, repeaters may be needed to boost the signal power.

[0006] Known power dividers include the Wilkinson and Gysel power dividers. The Wilkinson power divider, however, has a relatively large footprint and, because it is a passive divider, suffers from signal loss and accordingly requires amplification. Use of an amplifier with the Wilkinson power divider entails relatively large energy consumption characteristics. Other power dividers, such as the Gysel power divider, and repeaters known in the art also have relatively large footprints and relatively large energy consumption characteristics. Power dividers and repeaters known in the art at mm-wave frequencies require impedance

matching elements that include transformers and related circuits to optimally function. The inclusion of transformers and related circuits increases silicon die area and therefore cost.

[0007] For example, a three-channel automotive radar receiver known in the art from a first manufacturer consumes about 790 mW and a two-channel automotive radar known in the art from the first manufacturer consumes about 858 mW, which are relatively large power consumptions.

[0008] Accordingly, it would be desirable to have a power divider and/or a repeater with a relatively small footprint and a relatively small energy consumption.

SUMMARY OF THE INVENTION

[0009] The following presents a simplified summary of the invention in order to provide a basic understanding of some aspects of the invention. This summary is not an exhaustive overview of the invention. It is not intended to identify key or critical elements of the invention or to delineate the scope of the invention. Its sole purpose is to present some concepts in a simplified form as a prelude to the more detailed description that is discussed later.

[0010] Generally, the present disclosure is directed to CMOS gain elements and apparatus comprising such gain elements. CMOS gain elements may allow power dividers and repeaters to have relatively small footprints and relatively small energy consumptions.

[0011] In one embodiment, the present disclosure relates to a gain element, comprising: a first circuit comprising: a capacitor; a resistor, a first transistor, and a second transistor in parallel; wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor; and a second circuit comprising: a capacitor; a resistor, a first transistor, and a second transistor in parallel; wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor.

[0012] In one embodiment, the present disclosure relates to a splitter, comprising: a first gain element in series with a plurality of second gain elements, wherein the plurality of second gain elements are in parallel; wherein the first gain element and each second gain element each comprise: a first circuit comprising: a capacitor; a resistor, a first transistor, and a second transistor in parallel; wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor; and a second circuit comprising: a capacitor; a resistor, a first transistor, and a second transistor in parallel; wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor.

[0013] In one embodiment, the present disclosure relates to a semiconductor device, comprising: an oscillator configured to provide a first signal having a wavelength λ ; a first splitter configured to receive the first signal and provide a second signal and a third signal, wherein the second signal and the third signal each have the wavelength λ ; a first line configured to carry the second signal provided by the first splitter; a second line configured to carry the third signal provided by the first splitter; a transmitter splitter configured to receive the second signal via the first line and provide a plurality of transmitter signals, wherein each transmitter signal has the wavelength λ ; and a receiver splitter config-

ured to receive the second signal via the second line and provide a plurality of receiver signals, wherein each receiver signal has the wavelength λ ; wherein the first line has a length from $\lambda/4$ to $\lambda/32$ and the second line has a length from $\lambda/4$ to $\lambda/32$. The first splitter, the transmitter splitter, and the receiver splitter may each be a splitter referred to above. The semiconductor device may also comprise one or more repeaters, wherein each repeater may be a gain element referred to above.

BRIEF DESCRIPTION OF THE DRAWINGS

[0014] The disclosure may be understood by reference to the following description taken in conjunction with the accompanying drawings, in which like reference numerals identify like elements, and in which:

[0015] FIG. 1 illustrates a stylized block diagram representation of a radar system, in accordance with embodiments herein;

[0016] FIG. 2 illustrates a stylized block diagram description of the controller unit **140**, in accordance with embodiments herein;

[0017] FIG. 3 illustrates a stylized block diagram depiction of the radar front end unit of FIG. 1, in accordance with embodiments herein, is illustrated;

[0018] FIG. 4 illustrates a stylized block diagram of the transmitter unit of FIG. 3, in accordance with embodiments herein;

[0019] FIG. 5 illustrates a stylized block diagram of the receiver unit of FIG. 3, in accordance with embodiments herein;

[0020] FIG. 6 illustrates a stylized block diagram depiction of the signal processing unit of FIG. 1, in accordance with embodiments herein;

[0021] FIG. 7 illustrates a stylized block diagram depiction of the antenna unit of FIG. 1, in accordance with embodiments herein;

[0022] FIG. 8 illustrates a stylized block diagram depiction of an exemplary radar application of the system of FIG. 1, in accordance with embodiments herein;

[0023] FIG. 9 illustrates a stylized depiction of a local oscillator unit, in accordance with embodiments herein;

[0024] FIG. 10 illustrates a semiconductor device, in accordance with embodiments herein;

[0025] FIG. 11 illustrates a gain unit, in accordance with embodiments herein;

[0026] FIG. 12 illustrates a splitter, in accordance with embodiments herein; and

[0027] FIG. 13 illustrates a stylized depiction of a system for fabricating a semiconductor device, in accordance with embodiments herein.

[0028] While the subject matter disclosed herein is susceptible to various modifications and alternative forms, specific embodiments thereof have been shown by way of example in the drawings and are herein described in detail. It should be understood, however, that the description herein of specific embodiments is not intended to limit the invention to the particular forms disclosed, but on the contrary, the intention is to cover all modifications, equivalents, and alternatives falling within the spirit and scope of the invention as defined by the appended claims. Moreover, the stylized depictions illustrated in the drawings are not drawn to any absolute scale.

DETAILED DESCRIPTION

[0029] Various illustrative embodiments of the invention are described below. In the interest of clarity, not all features of an actual implementation are described in this specification. It will of course be appreciated that in the development of any such actual embodiment, numerous implementation-specific decisions must be made to achieve the developers' specific goals, such as compliance with system-related and business-related constraints, which will vary from one implementation to another. Moreover, it will be appreciated that such a development effort might be complex and time-consuming, but would nevertheless be a routine undertaking for those of ordinary skill in the art having the benefit of this disclosure.

[0030] The present subject matter will now be described with reference to the attached figures. Various structures, systems, and devices are schematically depicted in the drawings for purposes of explanation only and so as to not obscure the present disclosure with details that are well known to those skilled in the art. Nevertheless, the attached drawings are included to describe and explain illustrative examples of the present disclosure. The words and phrases used herein should be understood and interpreted to have a meaning consistent with the understanding of those words and phrases by those skilled in the relevant art. No special definition of a term or phrase, i.e., a definition that is different from the ordinary and customary meaning as understood by those skilled in the art, is intended to be implied by consistent usage of the term or phrase herein. To the extent that a term or phrase is intended to have a special meaning, i.e., a meaning other than that understood by skilled artisans, such a special definition will be expressly set forth in the specification in a definitional manner that directly and unequivocally provides the special definition for the term or phrase.

[0031] Embodiments herein provide for distribution of local oscillator signals to transmitters and receivers of a mm-wave system, e.g., a radar system, with low power consumption and small footprint, and without the use of Wilkinson, Gysel, or other power dividers.

[0032] For ease of illustration, embodiments herein is depicted within the context of a radar device, however, those skilled in the art would readily appreciate that the concepts disclosed herein may be implemented in other types of devices, such as high-speed communication devices, network devices, etc. Turning now to FIG. 1, a stylized block diagram representation of a radar system, in accordance with embodiments herein, is illustrated.

[0033] A system **100** may comprise a millimeter wave (mm-wave) device **110**, a database **170**, and a motor controller **180**. The mm-wave device **110** may be a radar device, a wireless communication device, a data network device, a video device, or the like. For illustrative purposes and for the sake of clarity and ease of description, the mm-wave device **110** is described in the context of a radar application; as such, the mm-wave device **110** may be often referred to below as a radar device **110**. However, those skilled in the art having benefit of the present disclosure would appreciate that the concepts described herein may be applied to a variety of type of mm-wave applications, including vehicle applications using radar signals, wireless network applications, data network applications, video and audio applications, etc.

[0034] The radar device **110** is capable of transmitting a radar signal, receiving a reflected signal resultant from the reflection of the radar signal, processing the reflected signal, and providing status data and/or reaction data for performing one or more actions based on the reflected signal. In one embodiment, the status data may include status of the target from which the reflection was received. Further, a motor controller **180** may control operations of one or more motors. Examples of motors may include devices that performing braking functions, steering functions, gear-shifting functions, accelerating functions, warning functions, and/or other actions relating to the operations of a road vehicle, an aircraft, and/or a watercraft. The motor controller **180** may use the reaction data and/or the status data to perform these control functions. The motor controller **180** may comprise one or more controllers that are capable of controlling a plurality of devices that perform the various operations of a road vehicle, an aircraft, and/or a watercraft.

[0035] The radar device **110** may comprise a radar front end unit **120**, an antenna unit **130**, a controller unit **140**, and a signal processing unit **150**. The radar front end unit **120** may comprise a plurality of components, circuit, and/or modules, and is capable of sending, receiving, processing, and reacting to radar signals. In one embodiment, the radar device **110** may be encompassed into a single integrated circuit (IC) chip. In some embodiments, the radar device **110** may be formed on a plurality of integrated circuits that are positioned on a single IC chip. In other embodiments, radar device **110** may be formed on single integrated circuit, which is shrouded into an IC chip.

[0036] The radar front end unit **120** is capable of providing a radar signal. In one embodiment, the frequency range of the radar signals processed by the radar device **110** may be in the range of about 10 GHz to about 90 GHz. The radar front end unit **120** is capable of generating a radar signal at a predetermined frequency range and directing the radar signal at a predetermined target area. The radar front end unit **120** is also capable of receiving a reflected signal based on the reflection of radar signal, and processing the reflected signal to determine a plurality of characteristics, such as the direction of a target, the speed of a target, the relative distance of a target, and/or the like. A more detailed description of the radar front end unit **120** is provided in FIG. 3 and accompanying description below.

[0037] In an alternative embodiment, the **120** may be a network communications front end unit, instead of a radar front end unit. In this embodiment, instead of receiving, transmitting, and/or processing radar signals, the device **110** may process network communications for various types of communication applications, such as packet data network communications, wireless (e.g., cellular communications, IEEE 802.11ad WiGig Technology, etc.), data communications, etc. The concepts disclosed herein in the context of radar applications may also be utilized for other types of applications, such as network communications, wireless communications, high-definition video applications, etc.

[0038] Continuing referring to FIG. 1, the antenna unit **130** may also comprise a transmission antenna and/or a receiver antenna. Further, each of the transmission and receiver antennas may comprise sub-portions to form an array of antennas. The transmission antennas are used for transmitting the radar signal, while the receiver antennas are used for receiving reflected signals resulting from reflections

of the radar signal. A more detailed description of the antenna unit **130** is provided in FIG. 7, and accompanying description below.

[0039] Continuing referring to FIG. 1, the radar device **110** may also comprise a signal processing unit **150**. The signal processing unit is capable of performing various analog and/or digital processing of the signals that are transmitted and/or received by the radar device **110**. For example, the radar signal transmitted by the radar device may be amplified prior to its transmission. Further, the reflected signal received by the radar device **110** may be sent through one or more analog filter stages. The reflected signals may then be converted/digitized into a digital signal by one or more analog-to-digital converters (A/D converters) in the signal processing unit **150**. Digital signal processing (DSP) may be performed on the digitized signal. A more detailed description of the signal processing unit **150** is provided in FIG. 6 and accompanying description below.

[0040] Continuing referring to FIG. 1, the radar device **110** may also comprise a controller unit **140**. The controller unit **140** may perform various control operations of the radar device **110**. These functions include generating a radar signal, transmitting the radar signal, receiving a reflected signal, processing the reflected signal, and perform one or more determinations of the location, direction, speed, or other parameters of a target based on the reflected signal. The controller unit **140** is capable of generating the status data and the reaction data described above.

[0041] Turning now to FIG. 2, a stylized block diagram description of the controller unit **140**, in accordance with embodiments herein, is provided. The controller unit **140** may comprise a processor unit **230** capable of controlling various function of the radar device **110**. The processor unit **230** may comprise a microprocessor, a microcontroller, a field programmable gate array (FPGA), an application-specific integrated circuit (ASIC), and/or the like.

[0042] The controller unit **140** may also comprise a logic unit **220**. The logic unit **220** may comprise a circuit that is capable of performing various logic operations, receiving data, and/or performing interface functions with respect to input data (data_in) and output data (data_out). The signal, data_in, may represent data derived from processing and analyzing the reflected signal. The signal, data_out, may represent data generated for performing one or more tasks as a result of the radar signal transmission and the reflected signal. For example, the data_out signal may be used to perform an action (e.g., braking, steering, accelerating, providing warnings, etc.) based on the radar signal transmission and reflected signal reception.

[0043] The controller unit **140** may also comprise a memory unit **210**. The memory unit **210** may comprise a non-volatile memory **214** and a RAM **212**. The non-volatile memory **214** may comprise FLASH memory and/or programmable read only (PROM) devices. The memory unit **210** is capable of storing operation parameters, program files, etc., for controlling various operations of the radar device **110**. Further, the memory unit **210** may store the status data and the reaction data described above. The memory unit **210** may also store data that may be used to program any FPGA devices in the radar device **110**. As such, the memory unit **210** may be subdivided into a program data memory, a status data memory, and a reaction data memory. This subdivision may be performed logically, physically, or based on both, logical and physical subdivisions.

[0044] Turning now to FIG. 3, a stylized block diagram depiction of the radar front end unit 120, in accordance with embodiments herein, is illustrated. The radar front end unit 120 may comprise a signal generation unit 310, a transmitter unit 320, and a receiver unit 330. The signal generation unit 310 is capable of generating a radar signal at a predetermined frequency. For example, a signal in the range of about 70 GHz to about 85 GHz may be generated. The signal generation unit 310 is capable of providing a radar signal for transmission. More detailed description of the signal generation unit 310 is provided below.

[0045] Continuing referring to FIG. 3, a signal for processing and transmission is provided by signal generation unit 310 to the transmitter unit 320. The transmitter unit 320 may comprise a plurality of filters, signal conditioning circuits, buffer, amplifiers, etc. for processing the signal from the signal generation unit 310. The transmission unit 320 provides a radar signal to be transmitted to the antenna unit 130.

[0046] FIG. 4 illustrates a stylized block diagram of the transmitter unit 320, in accordance with embodiments herein. Referring simultaneously to FIGS. 3 and 4, the transmitter unit 320 may comprise a plurality of similar transmitters, i.e., a 1st transmitter 410a, a 2nd transmitter 410b, through an Nth transmitter 410n (collectively “410”). In one embodiment, the 1st through Nth transmitters 410 may each process a single signal from the signal generation unit 310 and provide an output transmission signal to one or more antennas. In another embodiment, the signal generation unit 310 may provide a plurality of signals to the through Nth transmitters 410. For example, the signal generation unit 310 may provide a signal transmit signal for each transmitter 410, or alternatively, a 1st transmit signal for a first set of transmitters 410 and a 2nd transmit signal for a second set of transmitters 410.

[0047] Continuing referring to FIG. 3, a received signal (i.e., a reflected signal resulting from a reflection of the radar signal directed towards a target area) is provided to the receiver unit 330. The receiver unit 330 is capable of receiving the processed received signal from the signal processing unit 130. The receiver unit 330 is capable of performing analog-to-digital (A/D) conversion, signal buffering, DSP, etc. In some embodiments, the signal processing unit 130 may perform A/D conversions and DSP; however, in other embodiments, these tasks may be performed by the receiver unit 330. The receiver unit 330 is capable of directing the output signal, data_{out}, to the controller unit 140.

[0048] FIG. 5 illustrates a stylized block diagram of the receiver unit 320, in accordance with embodiments herein. Referring simultaneously to FIGS. 3 and 5, the receiver unit 320 may comprise a plurality of similar receivers, i.e., a 1st receiver 510a, a 2nd receiver 510b, through an Nth receiver 510n (collectively “510”). In one embodiment, the 1st through Nth receivers 510 may each process a single signal from the signal generation unit 310 and provide the signal to the controller unit 140. In another embodiment, they may provide a plurality of signals to the through Nth receiver 510. For example, the antenna unit 130 may provide a signal to each receiver 510, or alternatively, a 1st receiver signal for a first set of receivers 510, and a 2nd receiver signal for a second set of receivers 510.

[0049] Turning now to FIG. 6, a stylized block diagram depiction of the signal processing unit 150, in accordance

with embodiments herein is illustrated. The signal processing unit 150 may comprise an analog filter unit 610, an A/D converter 620, a DSP unit 630, and a memory 640. The analog filter unit 610 is capable of performing filtering as well as amplification of the analog mm-wave signal received by the signal processing unit 150. Noise filtering may be performed by the analog filter unit 610 prior to performing amplification of the analog mm-wave signal.

[0050] The A/D converter 620 is capable of converting the filtered and/or amplified analog signal into a digital signal. The A/D converter 620 may be capable of performing conversions of predetermined or varying accuracy. For example, the A/D converter 620 may have an accuracy of 12-bit, 24-bit, 36-bit, 48-bit, 64-bit, 96-bit, 128-bit, 256-bit, 512-bit, 1024-bit, or greater accuracy. The converted digital mm-wave signal is provided to the DSP unit 630.

[0051] The DSP unit 630 is capable of performing a variety of DSP operations on the digital mm-wave signal. For example, digital filtering of the digital mm-wave may be performed by the DSP unit 630. As an example, signal components outside of a predetermined frequency range, e.g., 70 GHz to about 85 GHz may be filtered to be of lower amplitude. In other instances, mathematical functions, such as Fast Fourier Transform (FFT), may be performed on the mm-wave signal. The processed digital output from the DSP unit 630 may be sent to the controller unit 140 for analysis. In other instances, the digital output may be buffered or stored into a memory 640. In some cases, the memory 610 may be a first-in-first-out (FIFO) memory. In other cases, the processed digital output from the DSP unit 630 may be stored in the memory unit 210 of the controller unit 140.

[0052] Turning now to FIG. 7, a stylized block diagram depiction of the antenna unit of FIG. 1, in accordance with embodiments herein, is illustrated. Millimeter-wave signals to be sent out (e.g., radar signals, network data signals, wireless communication signals, etc.) may be provided by the transmitter unit 320 (FIG. 3) to the transmit antenna 710. In one embodiment, the transmit antenna 710 may comprise a plurality of transmit antenna portions 715. The transmit antenna portions 715 are arranged in a predetermined pattern, e.g., an array matrix, as exemplified in FIG. 7.

[0053] Millimeter-wave signals that are to be received (e.g., radar signals, network data signals, wireless communication signals, etc.) may be captured by the receive antenna 720. The receive antenna 720 provides the received mm-wave signals to the receiver unit 330 (FIG. 3). In one embodiment, the receive antenna 720 may comprise a plurality of receive antenna portions 725. The receive antenna portions 725 are also arranged in a predetermined pattern, e.g., an array matrix exemplified in FIG. 7.

[0054] Turning now to FIG. 8, a stylized block diagram depiction of an exemplary radar application of the system 100, in accordance with embodiments herein is illustrated. FIG. 8 shows an exemplary implementation of the signal generation unit 310 (FIG. 3) and exemplary portions of the transmitter unit 320 and the receiver unit 330.

[0055] The signal generation unit 310 generates a signal (e.g., a radar signal) that is to be transmitted and directed to a target region, e.g., toward the area in front of a vehicle. A frequency modulated continuous wave (FMCW) generator 810 provides an mm-wave signal in the range of about 20 GHz. The FMCW generator 810 may be arranged to provide a low speed ramp (LSR) signal or a high speed ramp (HSR) signal. In alternative embodiment, the FMCW generator 810

may be replaced by a pulse train generator for application of a Pulse Doppler radar system.

[0056] Further, a reference signal is provided by a reference signal generator **812**. The mm-wave signal from the FMCW generator **810** and the reference signal are both sent to a digital phase lock loop (DPLL) **820**. The DPLL **820** locks the phase of the mm-wave signal from the FMCW generator **810** with the phase of the reference signal. The output of the DPLL **820** is sent to a digitally controlled oscillator (DCO) **825**. The output of the DCO is fed back to the DPLL. Thus, the DCO **825** is capable of providing a stable DCO signal. The DCO signal is, in one embodiment, about 20 GHz. A plurality of low dropout (LDO) regulators **827**, which may comprise a reference voltage, an error amplifier, a feedback voltage divider, and a plurality of pass elements, e.g., transistors. The LDO regulators **827** are arranged to provide a regulated voltage supply to the various portions of the circuit of FIG. 8. Generally, this regulated voltage supply is lower than the supply voltage.

[0057] The signal generation unit **310** may also comprise one or more local oscillator (LO) units **880**. The local oscillator unit **880** may be arranged to provide an oscillator chain for distributing mm-wave signals to a plurality of transmitters and receivers. In some embodiments, the digitally controlled, phase-locked output mm-wave signal (i.e., output of the DCO **825**) based on the FMCW signal and the reference signals may be provided by the local oscillator unit **880**. The local oscillator unit **880** may provide mm-wave signals to the transmitter unit **320** for transmitting mm-wave signals, and/or to the receiver unit **330** to perform mixer functions. The local oscillator unit **880** may comprise a phase lock loop and a local oscillator distribution circuitry. A more detailed description of the local oscillator distribution circuitry is provided in FIGS. 9-11 and accompanying description below.

[0058] In some embodiments, it is desirable to transmit an 80 GHz signal, for example in a vehicle radar application. The DCO **825** provides a 20 GHz signal, therefore, two frequency doublers may be used to multiply the 20 GHz signal to provide a 40 GHz, and then multiply the 40 GHz signal to provide an 80 GHz signal to transmit. Accordingly, a 1st frequency multiplier **830** is used to double the 20 GHz signal to produce a 40 GHz signal. A 2nd frequency multiplier **832** is used to double the 40 GHz signal to produce an 80 GHz signal. The output of the 2nd frequency multiplier **832** is provided to a power amplifier **840**. The output of the power amplifier **840** may be provided to the antenna for transmission. A power detector **842** may detect the power of the output of the power amplifier **840**, and may prompt feedback adjustments in order to maintain a predetermined power level of the transmit signal. In some embodiments, the transmitted signal may be 77 GHz signal, and the frequency of the DCO **825** is adjusted accordingly to provide the 77 GHz signal at the output of the 2nd frequency multiplier **832** and/or the 3rd frequency multiplier **835**.

[0059] A received signal may be processed by the circuit shown in FIG. 8. The received signal, e.g., from the signal processing unit **150**, is provided to a balun circuit **850**. The balun may comprise a transformer, and provides a differential output to a pre-amplifier **852**. After performing a pre-amplification of the received signal, the output from the pre-amplifier **852** is provided to the mixer **860**.

[0060] The mixer **860** is capable of combining the received signal from the pre-amplifier **852**, with an output

signal from a 3rd frequency multiplier **835**. The output of the 3rd frequency multiplier **835** is the doubled version of the 40 GHz signal from the 1st frequency multiplier. That is, the output of the 3rd frequency multiplier **835** is an 80 GHz reference signal. The mixer **860** receives the reference 80 GHz signal and in one embodiment, multiplies it to the received signal, which is a reflected or echo signal resulting from the reflection from the transmitted signal. The output of the mixer may be used to determine various characteristics regarding an object(s) from which the transmitted signal was reflected, including direction, location, trajectory, and/or speed of the object.

[0061] The output of the mixer **860** is provided to an analog baseband (ABB) unit **865**. The mixer **860** converts the incoming mm-wave signal using a local oscillator (which may be provided by local oscillator unit **880**) to lower the frequency of the signal. The analog baseband unit **865** can include a transimpedance amplifier (TIA), which may include one or more filters and/or other low frequency gain stages. The output of the ABB unit **865** is provided to an automatic gain control (AGC) and filter circuits **868**. A saturation detection circuit **872** may detect any saturation of the signal processed by the AGC/filter circuits **868** and perform responsive adjustment. The output of the AGC/filter circuits **868** is provided to an A/D converter **870**. The output of the A/D converter **870** may be provided to the controller unit **140** for further processing and responsive actions, such as digital signal processing (DSP).

[0062] FIG. 9 illustrates a stylized depiction of a local oscillator unit, in accordance with embodiments herein. The LO unit **880** depicted in FIG. 9 comprises a LO distribution chain utilizing splitters and repeaters, which can be scaled to accommodate various technology nodes. The repeaters and splitters of the LO unit **880** provide for distributing relatively smaller gain stages, thereby providing for avoiding a single large gain stage. This may result in improved stability at mm-wave frequencies.

[0063] The LO unit **880** may receive an mm-wave signal from the DCO **825**. The DCO signal is sent to an analog-digital phase lock loop (AD-PLL) **1005**. Upon performing a phase locking function, the phase-locked signal is provided to a 1st splitter **1020**. The 1st splitter **1020** may provide three outputs: a feedback phase lock loop signal to a feedback phase lock loop **1025**; a transmission signal to a transmission (TX) repeater-splitter **1050**; and a receiver signal to a receiver (RX) repeater-splitter **1060**. The repeater-splitters **1050**, **1060** are comprised of gain elements, wherein the splitting of the signals may be performed without using dividers, but using signal lines that connect between elements of the LO unit **880**, wherein the lengths of the signal lines are a predetermined fraction of the wavelength, λ , of the mm-wave signal (e.g., $\lambda/4$ to $\lambda/32$), and in one embodiment, $\lambda/10$).

[0064] The output from the TX repeater-splitter **1050** is provided to a TX repeater **1070** after a line length that is the predetermined fraction of the wavelength (e.g., $\lambda/10$). Likewise, the output from the RX repeater-splitter **1060** is provided to an RX repeater **1080** after a line length that is the predetermined fraction of the wavelength (e.g., $\lambda/10$). The output of the TX repeater **1070**, i.e., a TX output signal, is provided to one or more transmitter frequency multipliers **1090** associated with the transmitter unit **320** via a LO-TX line **910**. The output of the RX repeater **1080** is provided to one or more receiver frequency multipliers **1090** associated

with the receiver unit **330**, via a LO-RX line **920**. The TX-LO line **910** and the RX-LO line **920** are of a length that is the predetermined fraction of the wavelength (e.g., $\lambda/10$).

[0065] The transmitter unit **320** may comprise other circuitry that provides the signal to be transmitted to the TX antenna **710**. The receiver unit **330** may also comprise of various circuitry, such as a mixer (as exemplified above with regard to FIG. **8**), to which the receiver frequency multipliers **1095** provide an mm-wave signal. The output of the receiver frequency multiplier **330** may be provided to a mixer, along with the RX input signal from the RX antenna **720** to perform a mixing function.

[0066] The various repeater and splitter stages described in FIG. **9** may be comprised of gain elements comprising CMOS circuitry. The signal from the DCO **825** may be of a frequency such that the length of the LO lines between the elements of the LO unit **880** may be segmented to a fraction of the wavelength, λ (e.g., $\lambda/4$ to $\lambda/32$). In some embodiments, low and variable gain CMOS elements may be used to form the repeater and splitter circuitry of the LO unit **880**. The frequency multiplication described above may be an integer, e.g., 2, 3, 4, 5, In one embodiment, the integer 3 may be avoided as to reduce the third harmonic, which may be stronger than the second harmonic of the mm-wave signal.

[0067] Further, the implementation of the LO unit **880** may also provide for reduced area usage, and improved isolation between the transmission lines and the receiver lines. The output from the TX frequency multiplier **1090** may be provided to power amplifiers for transmission via the TX antenna **710**. The output from the receiver frequency multipliers **1095** may be provided to a mixer along with the received RX input signal. FIG. **10** illustrates a stylized depiction of a semiconductor device having a local oscillator distribution circuitry **1000** associated with the LO unit **880**, in accordance with embodiments herein. The local oscillator distribution circuitry **1000** comprises an oscillator **1010**. The oscillator **1010** provides a first signal having a wavelength λ . The oscillator **1010** may represent various elements, such as an FMCW generator a reference signal generator, a DPLL, a DCO, etc. As will be known to the person of ordinary skill in the art, the wavelength λ is related to the frequency f essentially according to the formula $f=c/\lambda$, where c is the speed of light in the medium through which the signal propagates. The speed of light will depend on the permittivity and permeability of the medium. For example, in a silicon die, if $f=20$ GHz, then $\lambda=6$ mm. As depicted, the oscillator **1010** provides a differential (or double ended) output. In other embodiments (not shown), the oscillator **1010** may provide a single ended (non-differential) output.

[0068] The local oscillator distribution circuitry **1000** also comprises the first splitter **1020** arranged to receive the first signal from the oscillator **1010** and provide a second signal and a third signal. The first splitter **1020** does not change the frequency or wavelength of the first signal. Accordingly, the second signal and the third signal each have the wavelength λ . As depicted, the first splitter **1020** also provides a signal to a feedback PLL **1025**, to assist in normal operation of the local oscillator distribution circuitry **1000**, as will be apparent to the person of ordinary skill in the art having the benefit of the present disclosure. The first splitter **1020** comprises a plurality of gain elements **1022**. The structure of the gain element **1022** will be described in FIG. **10** and accompanying description below.

[0069] The local oscillator distribution circuitry **1000** also comprises a first line **1030** arranged to carry the second signal provided by the first splitter, and a second line **1040** arranged to carry the third signal provided by the first splitter. Because the second signal and third signal are double ended, the first line and the second line each comprise two conductive elements, as depicted in FIG. **10**.

[0070] Desirably, the first line **1030** and the second line **1040** have lengths selected according to the wavelength(s) of the second signal and the third signal. Appropriate selection of line lengths reduces the likelihood and/or extent of matching. In one embodiment, the first line **1030** has a length from $\lambda/4$ to $\lambda/32$. In one embodiment, the second line **1040** has a length from $\lambda/4$ to $\lambda/32$.

[0071] In a further embodiment, the first line **1030** has a length from $\lambda/8$ to $\lambda/16$. In a further embodiment, the second line **1040** has a length from $\lambda/8$ to $\lambda/16$. Though not to be bound by theory, at shorter lengths (i.e., the greater the denominator x in λ/x), more repeaters will generally be required and the power consumption will generally be greater. At greater lengths (i.e., the lesser the denominator x in λ/x), fewer repeaters will generally be required, but reflections are more likely and mismatch losses will generally be higher.

[0072] In a particular embodiment, the first line **1030** has a length of $\lambda/10$ and the second line **1040** has a length of $\lambda/10$.

[0073] The local oscillator distribution circuitry **1000** further comprises a transmitter splitter **1050** arranged to receive the second signal via the first line **1030**, and provide a plurality of transmitter signals. Similarly to the first splitter **1020**, the transmitter splitter **1050** does not change the frequency or wavelength of the second signal. Accordingly, each transmitter signal has the wavelength λ .

[0074] The local oscillator distribution circuitry **1000** also comprises a receiver splitter **1060** arranged to receive the second signal via the second line **1040**, and provide a plurality of receiver signals. Similarly to the first splitter **1020** and the transmitter splitter **1050**, the receiver splitter **1060** does not change the frequency or wavelength of the second signal. Accordingly, each receiver signal has the wavelength λ .

[0075] The oscillator **1010**, the first splitter **1020**, the first line **1030**, the second line **1040**, the transmitter splitter **1050**, and the receiver splitter **1060** may be considered to be components of the AD-PLL **1005**.

[0076] In one embodiment, the local oscillator distribution circuitry **1000** may further comprise a plurality of third lines **1055**, wherein each third line **1055** is arranged to carry one transmitter signal provided by the transmitter splitter **1050**. As depicted in FIG. **10**, the local oscillator distribution circuitry **1000** comprises three third lines, **1055a**, **1055b**, and **1055c**. In other embodiments (not shown), the local oscillator distribution circuitry **1000** may comprise two, four, five, or another plural number of third lines **1055**.

[0077] In one embodiment, the local oscillator distribution circuitry **1000** may further comprise a plurality of fourth lines **1065**, wherein each fourth line **1065** is arranged to carry one receiver signal provided by the receiver splitter **1060**. As depicted in FIG. **10**, the local oscillator distribution circuitry **1000** comprises four third lines, **1065a**, **1065b**, **1065c**, and **1065d**. In other embodiments (not shown), the

local oscillator distribution circuitry **1000** may comprise two, three, five, or another plural number of fourth lines **1065**.

[**0078**] Desirably, each third line **1055** and each fourth line **1065** has a length selected according to the wavelength(s) of the transmitter signals and the receiver signals, respectively. In one embodiment, wherein each third line **1055** has a length from $\lambda/4$ to $\lambda/32$. In one embodiment, each fourth line **1065** has a length from $\lambda/4$ to $\lambda/32$.

[**0079**] In a further embodiment, each third line **1055** has a length from $\lambda/8$ to $\lambda/16$. In a further embodiment, each fourth line **1065** has a length from $\lambda/8$ to $\lambda/16$. In one particular embodiment, each third line **1055** has a length of $\lambda/10$ and each fourth line **1065** has a length of $\lambda/10$.

[**0080**] In one embodiment, the local oscillator distribution circuitry **1000** may additionally comprise a plurality of transmitter repeaters **1070**, wherein each transmitter repeater **1070** is arranged to receive one transmitter signal via one third line **1055** and repeat the transmitter signal. For example, as depicted in FIG. **10**, the local oscillator distribution circuitry **1000** comprises three transmitter repeaters **1070a**, **1070b**, and **1070c**, one for each of the third lines **1055a**, **1055b**, and **1055c**.

[**0081**] In one embodiment, the local oscillator distribution circuitry **1000** may also comprise a plurality of receiver repeaters **1080**, wherein each receiver repeater **1080** is arranged to receive one receiver signal via one fourth line **1065** and repeat the receiver signal. For example, as depicted in FIG. **10**, the local oscillator distribution circuitry **1000** comprises four receiver repeaters **1080a**, **1080b**, **1080c**, and **1080d**, one for each of the fourth lines **1065a**, **1065b**, **1065c**, and **1065d**.

[**0082**] The positions of transmitter repeaters **1070** and receiver repeaters **1080** in a semiconductor device having local oscillator distribution circuitry **1000** may be selected to minimize reflections and minimize signal losses.

[**0083**] As depicted in FIG. **10**, in one embodiment, the local oscillator distribution circuitry **1000** may yet further comprise a plurality of fifth lines **1075**, wherein each fifth line **1075** is arranged to carry one repeated transmitter signal provided by one transmitter repeater **1070**. For example, the local oscillator distribution circuitry **1000** depicted in FIG. **10** comprises three fifth lines, **1075a**, **1075b**, and **1075c**, of which fifth line **1075a** carries the repeated transmitter signal provided by transmitter repeater **1070a**, etc.

[**0084**] In one embodiment, the local oscillator distribution circuitry **1000** may additionally comprise a plurality of sixth lines **1085**, wherein each sixth line **1085** is arranged to carry one repeated receiver signal provided by one receiver repeater **1080**. For example, the local oscillator distribution circuitry **1000** depicted in FIG. **10** comprises four sixth lines, **1085a**, **1085b**, **1085c**, and **1085d**, of which sixth line **1085a** carries the repeated receiver signal provided by receiver repeater **1080a**, etc.

[**0085**] Desirably, each fifth line **1075** and each sixth line **1085** has a length selected according to the wavelength(s) of the repeated transmitter signals and the repeated receiver signals, respectively. In one embodiment, each fifth line **1075** has a length from $\lambda/4$ to $\lambda/32$. In one embodiment, each sixth line **1085** has a length from $\lambda/4$ to $\lambda/32$.

[**0086**] In a further embodiment, each fifth line **1075** has a length from $\lambda/8$ to $\lambda/16$. In a further embodiment, each sixth line **1085** has a length from $\lambda/8$ to $\lambda/16$. In one particular

embodiment, each fifth line **1075** has a length of $\lambda/10$ and each sixth line **1085** has a length of $\lambda/10$.

[**0087**] The various lengths at various stages may vary. For example, in one embodiment, the first line **1030** and the second line **1040** may have a first particular length; each third line **1055** and each fourth line **1065** may have a second particular length different from the first particular length; and each fifth line **1075** and each sixth line **1085** may have a third particular length different from the first particular length, the second particular length, or both.

[**0088**] The lengths of one or more of the first line **1030**, the second line **1040**, the third lines **1055**, the fourth lines **1065**, the fifth lines **1075**, and the sixth lines **1085** may be selected to minimize reflections and minimize signal losses.

[**0089**] Although FIG. **10** shows only one set of transmitter repeaters **1070** and one set of receiver repeaters **1080**, the local oscillator distribution circuitry **1000** may comprise additional sets of repeaters and additional sets of lines.

[**0090**] In one embodiment, the local oscillator distribution circuitry **1000** may further comprise the transmitter frequency multiplier **1090** arranged to multiply a frequency of each repeated transmitter signal. For example, the transmitter frequency multiplier **1090** may be arranged to multiply the frequency of each repeated transmitter signal by 2, 3, 4, or 5. In a particular embodiment, the transmitter frequency multiplier **1090** is arranged to multiply the frequency of each repeated transmitter signal by 4. A multiplier of 4 may be desirable because such a multiplier may be provided by a digitally controlled oscillator **825** and an ADPLL **1005**, which can be implemented in CMOS technologies, may function as a PLL **1025**. In some embodiments, the transmitter frequency multiplier **1090** may comprise a plurality of individual frequency multipliers that are arranged in series. The output of the transmitter frequency multiplier **1090** may be provided to the transmission antenna **710**. Techniques and circuits that multiply a frequency are known to the person of ordinary skill in the art or may be described in other patents or published patent applications assigned to GLOBAL-FOUNDRIES Inc., and need not be described further.

[**0091**] In one embodiment, the local oscillator distribution circuitry **1000** may additionally comprise a receiver frequency multiplier **1095** arranged to multiply a frequency of each repeated receiver signal. For example, the receiver frequency multiplier **1095** may be arranged to multiply the frequency of each repeated receiver signal by 2, 3, 4, or 5. In one particular embodiment, the receiver frequency multiplier **1095** is arranged to multiply the frequency of each repeated receiver signal by 4. In some embodiments, the receiver frequency multiplier **1095** may comprise a plurality of individual frequency multipliers that are arranged in series. The output of the receiver frequency multiplier **1095** may be provided to the mixer **860**.

[**0092**] Signals outputted by transmitter frequency multiplier **1090** may be provided to an array of transmitter antennas. Signals outputted by receiver frequency multiplier **1095** may be provided to an array of receiver antennas.

[**0093**] In one example, a semiconductor device having local oscillator distribution circuitry **1000** having three transmitters, four receivers, three transmitter repeaters **1070**, and four receiver repeaters **1080** consumes only 170 mW, which is far less than the over 1.6 W consumed by the prior art circuitry referred to in the background.

[**0094**] FIG. **11** depicts a gain element **1022**, in accordance with embodiments herein. The depicted gain element **1022**

comprises a first circuit **1100a**. The first circuit **1100a** comprises a capacitor **1110a**. The first circuit **1100a** also comprises a resistor **1120a**, a first transistor **1130a**, and a second transistor **1140a** in parallel. One of the first transistor **1130a** and the second transistor **1140a** is an NMOS transistor, and the other of the first transistor **1130a** and the second transistor **1140a** is a PMOS transistor.

[0095] The gain element **1022** also comprises a second circuit **1100b**. The second circuit **1100b** comprises a capacitor **1110b**. The second circuit **1100b** also comprises a resistor **1120b**, a first transistor **1130b**, and a second transistor **1140b** in parallel. One of the first transistor **1130b** and the second transistor **1140b** is an NMOS transistor, and the other of the first transistor **1130b** and the second transistor **1140b** is a PMOS transistor.

[0096] In one embodiment, each first transistor **1130a**, **1130b** is the PMOS transistor of its circuit **1100a**, **1100b** and each second transistor **1140a**, **1140b** is the NMOS transistor of its circuit **1100a**, **1100b**.

[0097] As depicted in FIG. 11, in the gain element **1022**, the first circuit **1100a** further comprises a first back gate voltage source **1135a** and a second back gate voltage source **1145a**. The second circuit **1100b** further comprises a first back gate voltage source **1135b** and a second back gate voltage source **1145b**. In other words, each first transistor **1130a**, **1130b** is arranged to receive a first back gate voltage and each second transistor **1140a**, **1140b** is arranged to receive a second back gate voltage.

[0098] In one embodiment, the first back gate voltage and the second back gate voltage may be adjustable, either in tandem within one circuit **1100**, independently from each other within one circuit **1100**, in tandem across both circuits **1100a** and **1100b** (i.e., for example, both the first back gate voltage source **1135a** and the second back gate voltage source **1135b** may provide the same voltage to the back gates of first transistors **1130a** and **1130b**), or completely independently (i.e., each of the four transistors **1130a**, **1130b**, **1140a**, and **1140b** may have its back gate voltage adjusted independently of the back gate voltages of the other three transistors). By adjusting one or both of the first back gate voltage and the second back gate voltage of one or both circuits **1100a** and **1100b**, the gain imparted by the gain element **1022** may be adjusted. This may allow convenient and/or energy-efficient adjustment of gain to a desired value before and/or during operation of a device comprising gain element **1022**.

[0099] In another embodiment, the first back gate voltage and the second back gate voltage may be fixed, either at the same value or at different values. For example, in one embodiment, each NMOS transistor may be arranged to receive a back gate voltage of 0.8 V and each PMOS transistor may be arranged to receive a back gate voltage of 0 V.

[0100] Although FIG. 11 depicts a double ended gain element **1022**, a single ended gain element having one circuit **1100** is also in accordance with embodiments herein.

[0101] The gain element **1022** may be operated with a number of parameters. A current of about 2.5 mA may allow a differential voltage gain of 4 dB when the signal frequency input to the gain element **1022** is 20 GHz. Also, the gain may be adjusted by varying the supply voltage, the back gate voltage to the first transistors **1130a**, **1130b**, the back gate voltage to the second transistors **1140a**, **1140b**, or two or more thereof. The first and second transistors **1130a**, **1130b**,

1140a, and **1140b** may be biased at any desirable level. For example, the transistors may be biased close to peak cut-off frequency (fT). Though not to be bound by theory, high frequency circuits generally require technologies with higher fT for optimal function. It is desirable to bias the devices in mm-wave circuits at current densities to operate at peak fT. In one embodiment, the first and second transistors **1130a**, **1130b**, **1140a**, and **1140b** are biased at 200 μm .

[0102] FIG. 12 depicts a splitter **1200**. The splitter **1200** comprises a first gain element **1210** in series with a plurality of second gain elements **1220**, wherein the plurality of second gain elements are in parallel. Although FIG. 12 depicts three second gain elements **1220a**, **1220b**, and **1220c**, in embodiments herein, the splitter **1200** may comprise two, four, five, or another plural number of second gain elements **1220**.

[0103] The first gain element **1210** may be as described above regarding gain element **1022** depicted in FIG. 10. Each second gain element **1220** may also be as described above regarding gain element **1022** depicted in FIG. 10. For example, each first transistor of each circuit of each of the first gain element and the plurality of the second gain elements may be arranged to receive first back gate voltages and the second transistor of each circuit of each of the first gain element and the plurality of the second gain elements may be arranged to receive second back gate voltages. The back gate voltage of each transistor may be adjusted independently or in tandem with any one or more other transistors' back gate voltages. For another example, each first transistor of each circuit of each gain element may be a PMOS transistor and each second transistor of each circuit of each gain element may be an NMOS transistor.

[0104] Although FIG. 12 depicts a single ended splitter **1200**, this is for convenience only. A double ended splitter wherein the first gain element **1210** and each second gain element **1220** has two circuits **1100a**, **1100b** is also in accordance with embodiments herein.

[0105] Turning now to FIG. 13, a stylized depiction of a system **1300** for fabricating a semiconductor device package having a local oscillator distribution circuitry **800**, in accordance with embodiments herein, is illustrated. A system **1300** of FIG. 13 may comprise a semiconductor device processing system **1310** and an integrated circuit design unit **1340**. The semiconductor device processing system **1310** may manufacture integrated circuit devices based upon one or more designs provided by the integrated circuit design unit **1340**.

[0106] The semiconductor device processing system **1310** may comprise various processing stations, such as etch process stations, photolithography process stations, CMP process stations, etc. Each of the processing stations may comprise one or more processing tools **1314** and or metrology tools **1316**. Feedback based on data from the metrology tools **1316** may be used to modify one or more process parameters used by the processing tools **1314** for performing process steps.

[0107] The semiconductor device processing system **1310** may also comprise an interface **1312** that is capable of providing communications between the processing tools **1314**, the metrology tools **1316**, and a controller, such as the processing controller **1320**. One or more of the processing steps performed by the semiconductor device processing system **1310** may be controlled by the processing controller **1320**. The processing controller **1320** may be a workstation

computer, a desktop computer, a laptop computer, a tablet computer, or any other type of computing device having one or more software products that are capable of controlling processes, receiving process feedback, receiving test results data, performing learning cycle adjustments, performing process adjustments, etc.

[0108] The semiconductor device processing system **1310** may produce integrated circuits (e.g., semiconductor devices having local oscillator distribution circuitry **800**) on a medium, such as silicon wafers. More particularly, in one embodiment, the semiconductor device processing system **1310** may produce a gain element, having: a first circuit having: a capacitor; a resistor in series with the capacitor; and a first transistor in series with a second transistor; wherein the first transistor and the second transistor are in parallel with the resistor, one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor; and a second circuit having: a capacitor; a resistor in series with the capacitor; and a first transistor in series with a second transistor; wherein the first transistor and the second transistor are in parallel with the resistor, one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor.

[0109] In another embodiment, the semiconductor device processing system **1310** may produce a splitter, having: a first gain element in series with a plurality of second gain elements, wherein the plurality of second gain elements are in parallel; wherein the first gain element and each second gain element each comprise: a first circuit having: a capacitor; a resistor in series with the capacitor; and a first transistor in series with a second transistor; wherein the first transistor and the second transistor are in parallel with the resistor, one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor; and a second circuit having: a capacitor; a resistor in series with the capacitor; and a first transistor in series with a second transistor; wherein the first transistor and the second transistor are in parallel with the resistor, one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor.

[0110] In yet another embodiment, the semiconductor device processing system **1310** may produce a semiconductor device, having: an oscillator arranged to provide a first signal having a wavelength λ ; a first splitter arranged to receive the first signal and provide a second signal and a third signal, wherein the second signal and the third signal each have the wavelength λ ; a first line arranged to carry the second signal provided by the first splitter; a second line arranged to carry the third signal provided by the first splitter; a transmitter splitter arranged to receive the second signal via the first line and provide a plurality of transmitter signals, wherein each transmitter signal has the wavelength λ ; and a receiver splitter arranged to receive the second signal via the second line and provide a plurality of receiver signals, wherein each receiver signal has the wavelength λ ; wherein the first line has a length from $\lambda/4$ to $\lambda/32$ and the second line has a length from $\lambda/4$ to $\lambda/32$. The first splitter, the transmitter splitter, and the receiver splitter may each be a splitter referred to above. The semiconductor device may

also comprise one or more repeaters, wherein each repeater may be a gain element referred to above.

[0111] The production of integrated circuits by the semiconductor device processing system **1310** may be based upon the circuit designs provided by the integrated circuit design unit **1340**. The semiconductor device processing system **1310** may provide processed integrated circuits/devices **1315** on a transport mechanism **1350**, such as a conveyor system. In some embodiments, the conveyor system may be sophisticated clean room transport systems that are capable of transporting semiconductor wafers. In one embodiment, the semiconductor device processing system **1310** may comprise a plurality of processing steps, e.g., the 1st process step, the 2nd process step, etc., as described above.

[0112] In some embodiments, the items labeled “1215” may represent individual wafers, and in other embodiments, the items **1315** may represent a group of semiconductor wafers, e.g., a “lot” of semiconductor wafers. The integrated circuit or device **1315** may comprise a transistor, a capacitor, a resistor, a memory cell, a processor, and/or the like.

[0113] The integrated circuit design unit **1340** of the system **1300** is capable of providing a circuit design that may be manufactured by the semiconductor device processing system **1310**. This may include information regarding the components of the local oscillator distribution circuitry **800** described above.

[0114] The integrated circuit design unit **1340** may be capable of determining the number of devices (e.g., processors, memory devices, etc.) to place in a device package. Based upon such details of the devices, the integrated circuit design unit **1340** may determine specifications of the devices that are to be manufactured. Based upon these specifications, the integrated circuit design unit **1340** may provide data for manufacturing a semiconductor device package described herein.

[0115] The system **1300** may be capable of performing analysis and manufacturing of various products involving various technologies. For example, the system **1300** may receive design and production data for manufacturing devices of CMOS technology, Flash technology, BiCMOS technology, power devices, memory devices (e.g., DRAM devices), NAND memory devices, and/or various other semiconductor technologies. This data may be used by the system **1300** to fabricate semiconductor devices described herein.

[0116] The particular embodiments disclosed above are illustrative only, as the invention may be modified and practiced in different but equivalent manners apparent to those skilled in the art having the benefit of the teachings herein. For example, the process steps set forth above may be performed in a different order. Furthermore, no limitations are intended to the details of construction or design herein shown, other than as described in the claims below. It is therefore evident that the particular embodiments disclosed above may be altered or modified and all such variations are considered within the scope and spirit of the invention. Accordingly, the protection sought herein is as set forth in the claims below.

What is claimed is:

1. A semiconductor device, comprising:
 - a first line configured to carry a first signal having a wavelength λ ;

- a second line configured to carry a second signal having a wavelength λ ;
 - a transmitter splitter configured to receive the second signal via the first line and provide a plurality of transmitter signals, wherein each transmitter signal has the wavelength λ ; and
 - a receiver splitter configured to receive the second signal via the second line and provide a plurality of receiver signals, wherein each receiver signal has the wavelength λ ;
- wherein the first line has a length from $\lambda/4$ to $\lambda/32$ and the second line has a length from $\lambda/4$ to $\lambda/32$.
2. The semiconductor device of claim 1, wherein:
 - the first line has at least one of a length from $\lambda/8$ to $\lambda/16$, or a length of $\lambda/10$; and
 - the second line has at least one of a length from $\lambda/8$ to $\lambda/16$, or a length of $\lambda/10$.
 3. The semiconductor device of claim 1, further comprising a first splitter configured to receive an input signal having a wavelength λ and provide the first signal and the second signal.
 4. The semiconductor device of claim 3, wherein the first splitter, the transmitter splitter, and the receiver splitter each comprise:
 - a first gain element in series with a plurality of second gain elements, wherein the plurality of second gain elements are in parallel,
 - wherein the first gain element and each second gain element each comprise:
 - a first circuit comprising:
 - a capacitor; and
 - a resistor, a first transistor, and a second transistor in parallel;
 - wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor; and
 - a second circuit comprising:
 - a capacitor; and
 - a resistor, a first transistor, and a second transistor in parallel;
 - wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor.
 5. The semiconductor device of claim 3, further comprising at least one of:
 - an oscillator for providing the input signal; or
 - a phase lock loop adapted to receive a reference signal and a frequency modulated continuous wave (FMCW) signal and provide the input signal, wherein the input signal is phase locked.
 6. The semiconductor device of claim 1, further comprising:
 - a plurality of third lines, wherein each third line is configured to carry one transmitter signal provided by the transmitter splitter;
 - a plurality of fourth lines, wherein each fourth line is configured to carry one receiver signal provided by the receiver splitter;
 - a plurality of transmitter repeaters, wherein each transmitter repeater is configured to receive one transmitter signal via one third line and repeat the transmitter signal; and
 - a plurality of receiver repeaters, wherein each receiver repeater is configured to receive one receiver signal via one fourth line and repeat the receiver signal;

wherein each third line has a length from $\lambda/4$ to $\lambda/32$ and each fourth line has a length from $\lambda/4$ to $\lambda/32$.
 7. The semiconductor device of claim 6, wherein:
 - each third line has at least one of a length from $\lambda/8$ to $\lambda/16$, or a length of $\lambda/10$; and
 - each fourth line has at least one of a length from $\lambda/8$ to $\lambda/16$, or a length of $\lambda/10$.
 8. The semiconductor device of claim 6, further comprising:
 - a plurality of fifth lines, wherein each fifth line is configured to carry one repeated transmitter signal provided by one transmitter repeater;
 - a plurality of sixth lines, wherein each sixth line is configured to carry one repeated receiver signal provided by one receiver repeater;
 - a transmitter frequency multiplier configured to multiply a frequency of each repeated transmitter signal; and
 - a receiver frequency multiplier configured to multiply a frequency of each repeated receiver signal;

wherein each fifth line has a length from $\lambda/4$ to $\lambda/32$ and each sixth line has a length from $\lambda/4$ to $\lambda/32$.
 9. The semiconductor device of claim 8, wherein the transmitter frequency multiplier is configured to multiply the frequency of each repeated transmitter signal by 2, 3, 4, or 5, and the receiver frequency multiplier is configured to multiply the frequency of each repeated receiver signal by 2, 3, 4, or 5.
 10. The semiconductor device of claim 9, wherein each fourth line has a length of $\lambda/10$ and each fifth line has a length of $\lambda/10$.
 11. The semiconductor device of claim 1, wherein the transmitter splitter is configured to provide three transmitter signals and the receiver splitter is configured to provide four receiver signals.
 12. A semiconductor device, comprising:
 - a phase lock loop configured to provide a first millimeter-wave (mm-wave) signal having a wavelength, λ ;
 - a first splitter configured to receive the first signal and provide a first transmit signal and a first receive signal, wherein the transmit signal and the receive signal each have the wavelength
 - a transmitter splitter configured to receive the first transmit signal and provide a second transmit signal on a second transmit line and a third transmit signal on a third transmit line, wherein the second and third transmit signals each have the wavelength λ ; and
 - a receiver splitter configured to receive the first receive signal and provide a second receive signal on a second receive line and a third receive signal on a third receive line, wherein the second and third receive signals each have the wavelength λ ;

wherein each of the first, second, and third receive lines and the first, second, and third transmit lines each has a length from $\lambda/4$ to $\lambda/32$.
 13. The semiconductor device of claim 12, wherein each of the first splitter, the transmitter splitter, the receiver splitter, the transmitter repeater, and the receiver repeater each comprise at least one gain element, comprising:

a first circuit comprising:
 a capacitor; and
 a resistor, a first transistor, and a second transistor in parallel;
 wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor; and
 a second circuit comprising:
 a capacitor; and
 a resistor, a first transistor, and a second transistor in parallel;
 wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor.

14. The gain element of claim **13**, wherein each first transistor is configured to receive a first back gate voltage and each second transistor is configured to receive a second back gate voltage.

15. The gain element of claim **14**, wherein the first back gate voltage is adjustable and each the second back gate voltage is adjustable.

16. The gain element of claim **14**, wherein each first transistor is the PMOS transistor of its circuit and each second transistor is the NMOS transistor of its circuit.

17. A splitter, comprising:
 a first gain element in series with a plurality of second gain elements, wherein the plurality of second gain elements are in parallel;
 wherein the first gain element and each second gain element each comprise:

a first circuit comprising:
 a capacitor; and
 a resistor, a first transistor, and a second transistor in parallel;
 wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor; and
 a second circuit comprising:
 a capacitor; and
 a resistor, a first transistor, and a second transistor in parallel;
 wherein one of the first transistor and the second transistor is an NMOS transistor, and the other of the first transistor and the second transistor is a PMOS transistor.

18. The splitter of claim **17**, wherein each first transistor of each circuit of each of the first gain element and the plurality of the second gain elements is configured to receive a first back gate voltage and the second transistor of each circuit of each of the first gain element and the plurality of the second gain elements is configured to receive a second back gate voltage.

19. The splitter of claim **18**, wherein the first back gate voltage is adjustable and the second back gate voltage is adjustable.

20. The splitter of claim **18**, wherein each first transistor of each circuit of each gain element is a PMOS transistor and each second transistor of each circuit of each gain element is an NMOS transistor.

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